Docket No: 294550U\$

	Applicant Initia	ited Interv	iew Requ	est F	orm				
Application No.: 10/588,7	03 First Nam	ed Applicant:	Jean DIJ	ON					
Examiner: _Marianne PAD	GETT Art Unit	1715	Status of A	pplica	tion: N	on-Fina	l Offic	e Acti	ion
Tentative Participants: (1) Examiner Padgett (3)		_ ''	Jacob Do						
Proposed Date of Interview (1) [] Telephonic Exhibit To Be Shown or D If yes, provide brief descri	w; July 21, 2011 (2) [XXXX] Personal emonstrated: [] Y.	(3)[Propose Video Co (X] NO	d Time	e: <u>1:3</u>				
	Issue	s To Be Di	scussed						
Issues (Rej., Obj., etc)	Claims/Fig. #s	Prior Art		Dis	cussed	Ag	reed	Not	Agreed
(1) Enablement	1, 2, 6-9, 13-17, 21, and 23-25			Į]	I]	ſ]
(2) Written Description	I, 2, 6-9, 13-17, 21, and 23-25			Į]	I	1	ſ]
(3) Indefiniteness	21 and 24			Ţ	1	ĺ]	[]
(4) §102/§103	1, 2, 6, 8, 9, 13, 14, 16, 17, 21, 23, and 24	Ida Lee		Ţ	1	[]	Ţ	1
[XXXX] Continuation Shee Brief Description of Argur See Continuation Sheet									
An interview was conducted NOTE:									
This form should be comp § 713.01). This application will not be intelyiew. Therefore, application is possible (Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Applicant/Appl	e delayed from issue beca licant is advised to file a s	use of applic tatement of t	ant's failu	re to su ce of t	ibmit a v his inter	vritten	recor	d of th	is

Applicant Initiated Interview Request Form Continuation Sheet (U.S.P.A. No. 10/588,703)

Issues To Be Discussed (cont'd)

Issue	Rejection	Claim	Prior Art Ida Lee and Lee		
(5)	§103	25			
(6)	§103	7 and 15	Ida Lee and Choi		
(7)	§102/§103	1, 2, 6, 8, and 9	Gao		
(8)	ODP	1, 2, 6-9, 13-17, 21, and 23-25	U.S.P.A. No. 10/546,284, Ida Lee, and Gao		
(9)	ODP	1, 2, 6, 8, 9, 13, 14, 16, 17, 21, and 23-25	U.S.P. No. 7,544,547, Ida Lee, and Gao		
(10)	ODP	1, 2, 6-9, 13-17, 21, and 23-25	U.S.P.A. No. 11/915,238, Ida Lee, and Gao		

Brief Description of Arguments to be Presented (cont'd)

Focus on prior art rejections (issues (4) to (7)). Possible amendments to claims 1, 13, and 21 to specify:

- (1) each of the layers of catalytic material is formed as a "continuous film";
- (2) the droplet shaped bodies are formed by performing a heat treatment at "200C-500C"; and/or
- (3) the waiting phases during deposition of the catalytic material are longer than the deposition phases.